

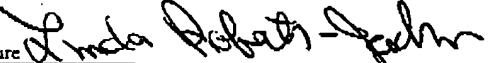
10/659,778

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I hereby certify that this paper and fee are being TRANSMITTED VIA FACSIMILE TO: Assistant Commissioner for Patents, P. O. Box 1450, ALEXANDRIA, VA 22313-1450. Date of Deposit: 10/11/05 Name of Person Making Deposit: Linda Roberts-Jackson

Signature 

In the United States Patent and Trademark Office

<i>Date:</i>	10/11/05		
<i>In re Application of:</i>	Edward Barth, et al.	<i>Filed:</i>	9/10/03
<i>For:</i>	Dual-Damascene Interconnect Structure Using Low Stress Fluorosilicate Insulator with Copper Conductors		
<i>Serial Number:</i>	10/659,778	<i>Confirmation No.</i>	5615
<i>Art Unit:</i>	2822	<i>Examiner:</i>	Novacek, Christy L.

AFTER FINAL AMENDMENT

Hon. Commissioner of Patents and Trademarks  
P. O. Box 1450  
Alexandria, VA 23313-1450

Dear Sir:

In response to the final Office Action dated July 13, 2005, Applicants submit the following amendments and remarks: